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	Filing Date		2004-12-20		
	First Named Inventor	Naok	i Yoshida		
	Art Unit		2623		
	Examiner Name Not Y		of Yet Assigned		
	Attorney Docket Numb	or	SONYJP 3 3-309		

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	2	09-046713	JP			1997-02-14	Tokyo Shibaura Ele Co	ectric		×
	3	10-313449	JP			1998-11-24	Matsushita Electric Co Ltd	Ind		×

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Attornov Docket Number		SONV ID 2 2 200		

	4	11-103452	JP		1999-04-13	Hitachi Ltd et al.		×
	5	11-327717	JP		1999-11-30	Digital Vision Lab Kk		×
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